

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

Claim 1. (canceled).

2. (currently amended): The resist stripper according to Claim 1 ~~26~~, wherein the quaternary ammonium salt is at least one member selected from the group consisting of quaternary ammonium hydroxide, a quaternary ammonium carbonate, a quaternary ammonium carboxylate and a quaternary ammonium peroxycarboxylate.

3. (currently amended): The resist stripper according to Claim 1 ~~26~~, wherein the quaternary ammonium salt is quaternary ammonium hydroxide.

4. (original): The resist stripper according to Claim 2, wherein the carboxylic acid in the quaternary ammonium carboxylate is an aromatic carboxylic acid.

5. (original): The resist stripper according to Claim 4, wherein the carboxylic acid in the quaternary ammonium carboxylate is at least one member selected from the group consisting of benzoic acid, salicylic acid and phthalic acid.

6. (currently amended): The resist stripper according to Claim 1 ~~26~~, wherein the quaternary ammonium in the quaternary ammonium salt is at least one member selected from the

group consisting of a tetraalkyl ammonium, a benzyltrialkyl ammonium and an alkyl-hydroxyalkyl ammonium.

7. (currently amended): The resist stripper according to Claim ~~1~~26, wherein the quaternary ammonium in the quaternary ammonium salt is a tetraalkyl ammonium.

Claims 8 and 9 (canceled).

10. (currently amended): The resist stripper according to Claim ~~1~~ 26, wherein the hydrogen peroxide and the quaternary ammonium salt are peroxyhydrate of the quaternary ammonium salt.

Claims 11 to 17 (canceled).

18. (currently amended): The resist stripper according to Claim ~~1~~ 26, for stripping of a titanium oxide.

19. (currently amended): The resist stripper according to Claim ~~1~~ 26, for stripping of a resist or a resist residue remaining after development of a photoresist and formation of a circuit.

Claims 20-22 (canceled).

23. (previously presented): The resist stripper according to Claim 10, wherein the peroxyhydrate of the quaternary ammonium salt is peroxyhydrate of tetramethylammonium hydroxide.

24. (previously presented): The resist stripper according to Claim 10, wherein the peroxyhydrate of the quaternary ammonium salt is peroxyhydrate of tetraethylammonium hydroxide.

Claim 25 (canceled).

26. (previously presented): A resist stripper which consists of hydrogen peroxide, a quaternary ammonium salt, water and a water soluble organic solvent.

27. (previously presented): The resist stripper according to Claim 26, wherein the water soluble organic solvent is at least one member selected from the group consisting of a sulfoxide, a sulfone, an amide, a lactam, an imidazolidinone, a glycol and a glycol ether.

28. (previously presented): The resist stripper according to Claim 26, wherein the water soluble organic solvent is dimethyl sulfoxide.

Claims 29, 30 and 31 (canceled).